

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: **Miwa KOZAWA et al.**

Art Unit: **1722**

Application Number: **10/720,097**

Examiner: **Daborah Chacko Davis**

Filed: **November 25, 2003**

Confirmation Number: **4454**

For: **PROCESS FOR FORMING RESIST PATTERN, SEMICONDUCTOR DEVICE
AND FABRICATION THEREOF**

Attorney Docket Number: **032132**
Customer Number: **38834**

PETITION FOR EXTENSION OF TIME

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

December 1, 2010

Sir:

Applicant petitions the Commissioner for Patents to extend the time for response to the Office Action dated August 4, 2010 for one month from November 4, 2010 to December 4, 2010.

Attached please find payment of \$130.00 for the extension of time. If any additional fees are due in connection with this paper, please charge Deposit Account No. 50-2866.

Respectfully submitted,

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/Kenneth H. Salen/

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